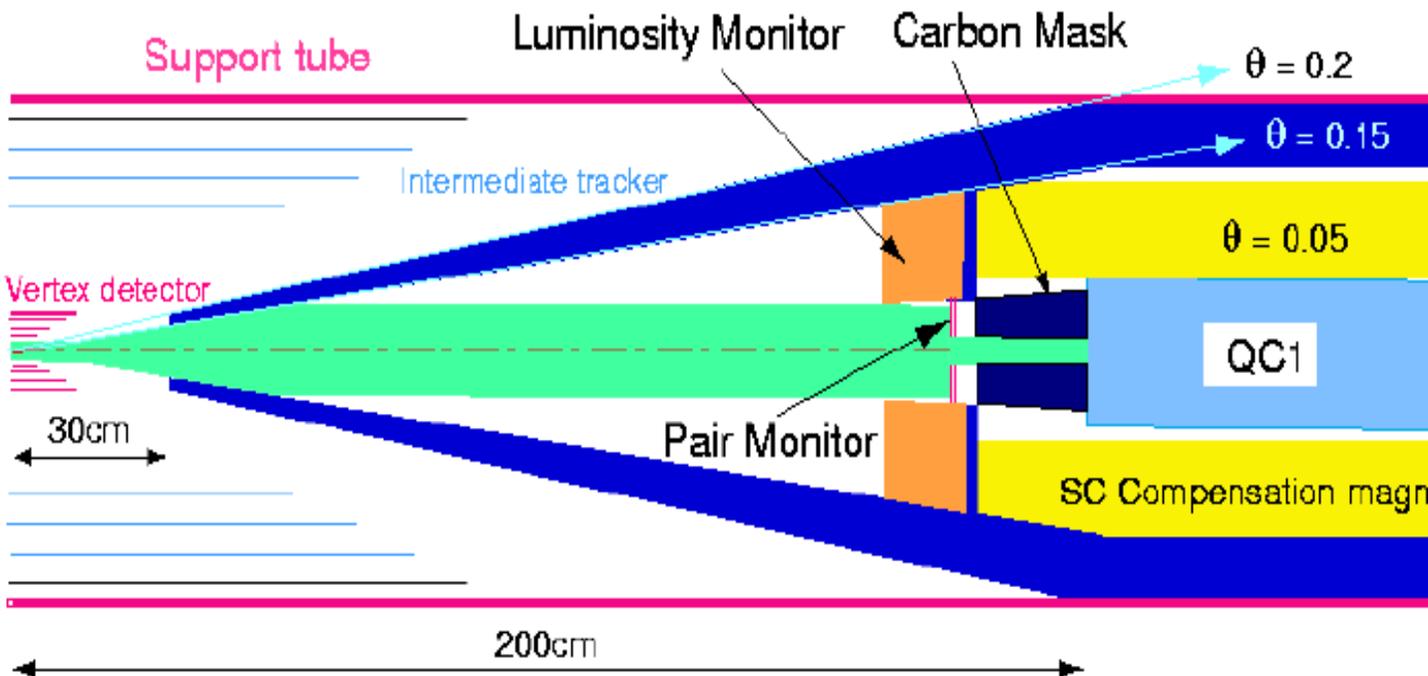
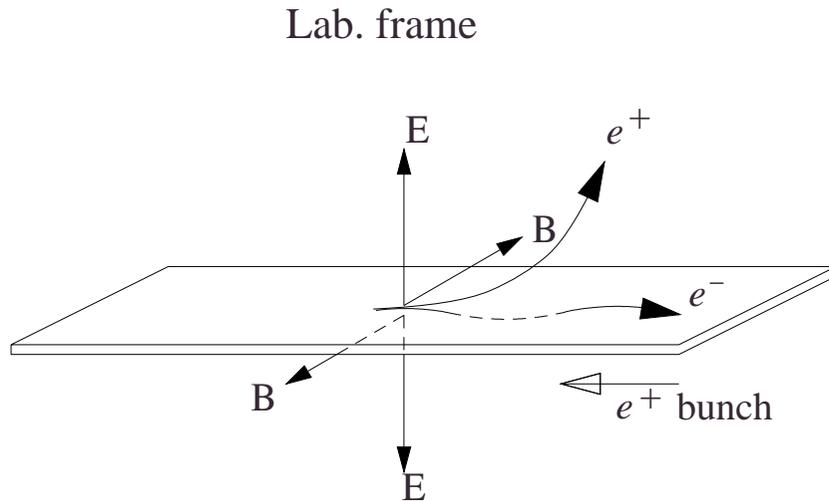


Pair Monitor for LCs

- Large number of pairs/bunch created by QED process $\gamma\gamma \rightarrow e^+e^-$
- Same sign particle acquire Pt kick by EM field of on-coming bunch
- P_t and Φ distribution of deflected e^+ (e^-) can be used to measure σ_x and σ_y of on-coming bunches

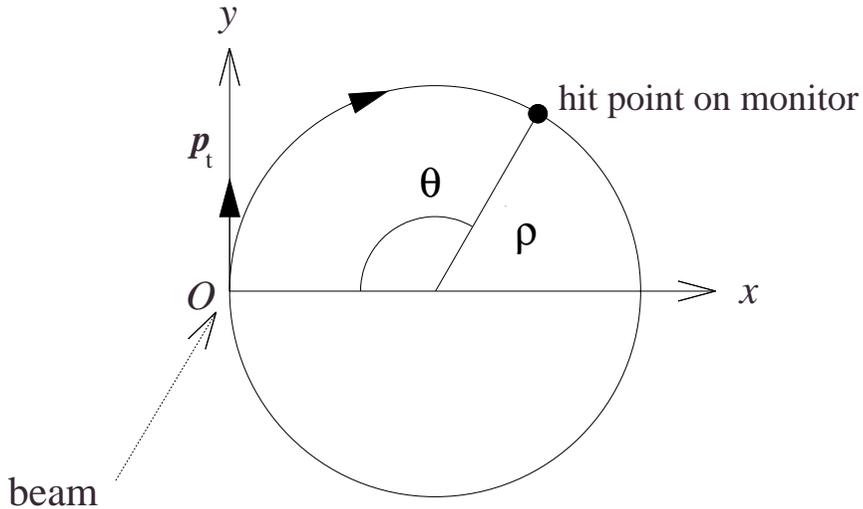


Kinematic Configuration of Pair 'Background'



- $|E| = |B|$
→ no force from the co-moving bunch.
- $E(\text{dyne/esu}) = B(\text{gauss}) \sim 4 \times 10^7$
→ $r \sim 170 \mu\text{m}$ for $p = 300 \text{ MeV}/c$.
($\sigma_z \sim 80 \mu\text{m}$)
- For an incoming e^+ bunch,
 e^- oscillates around the beam plane.
 e^+ acquires a large p_t kick (vertical).
- Round beam → no ϕ dependence,
 ϕ dependence → σ_y/σ_x ratio.

Hit Location on the Pair Monitor



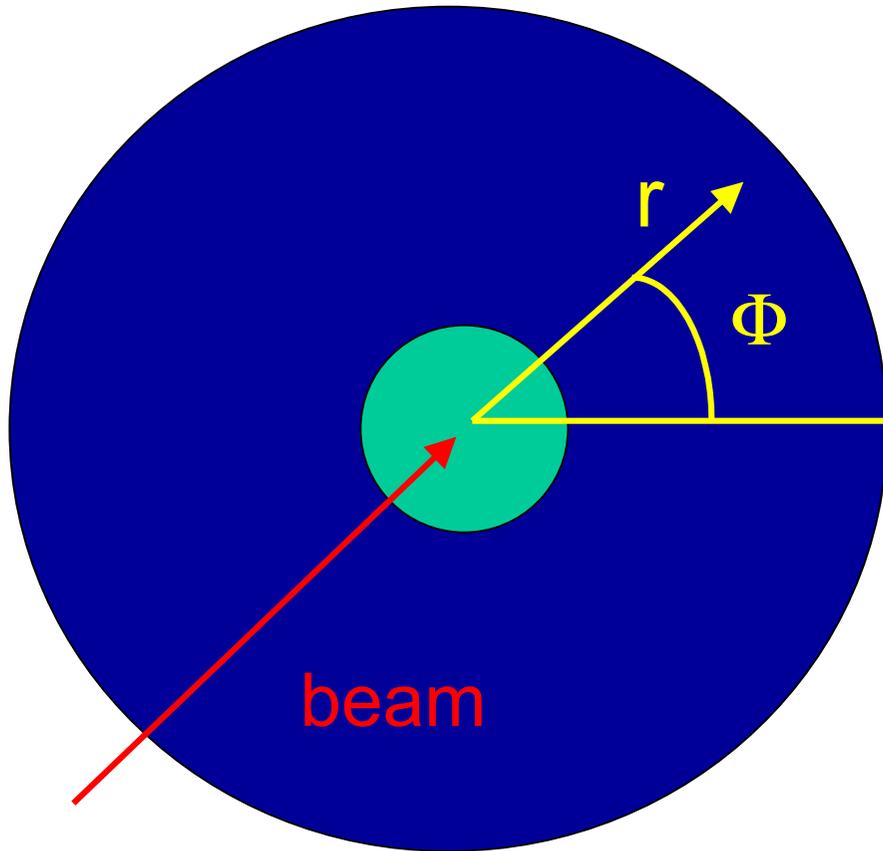
$$\rho(\text{cm}) = \frac{p_t(\text{MeV}/c)}{3B_0(\text{Tesla})}, \quad \theta = \frac{3B_0(\text{Tesla})L(\text{cm})}{p_z(\text{MeV}/c)}$$

L : distance to IP

- ρ measures p_t and θ measures p_z .
- For $\sqrt{s} = 500 \text{ GeV}$, $N_{\text{bunch}} \sim 10^{10}$
and $\sigma_{x/y/z} = 260\text{nm}/3\text{nm}/80\mu\text{m}$,

$$p_{t\text{max}} \sim 20\text{MeV}/c \rightarrow \rho = 3.3\text{cm} \text{ (2Tesla)}$$

- For $L = 176 \text{ cm}$, $p_z \sim 350 \text{ MeV}/c \rightarrow \theta \sim \pi$.
- Look at ϕ distribution for $r = 5 \sim 7 \text{ cm}$.

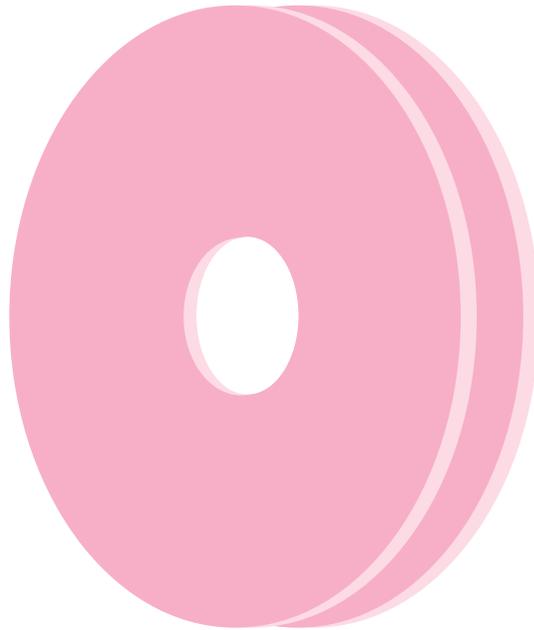


$$r \cong p_t \cong (N, (\ln \sigma_x)^{-1}, \cancel{\sigma_y})$$

$$\text{Azimuthal angle } \Phi \cong (\sigma_x / \sigma_y)$$

Pair Monitor

as a beam profile monitor



~~single~~ Active Pixel Sensor

~~double layer of silicon disks~~

pixel size 100 x 100 μm^2

thickness 300 μm

inner radius 2 cm

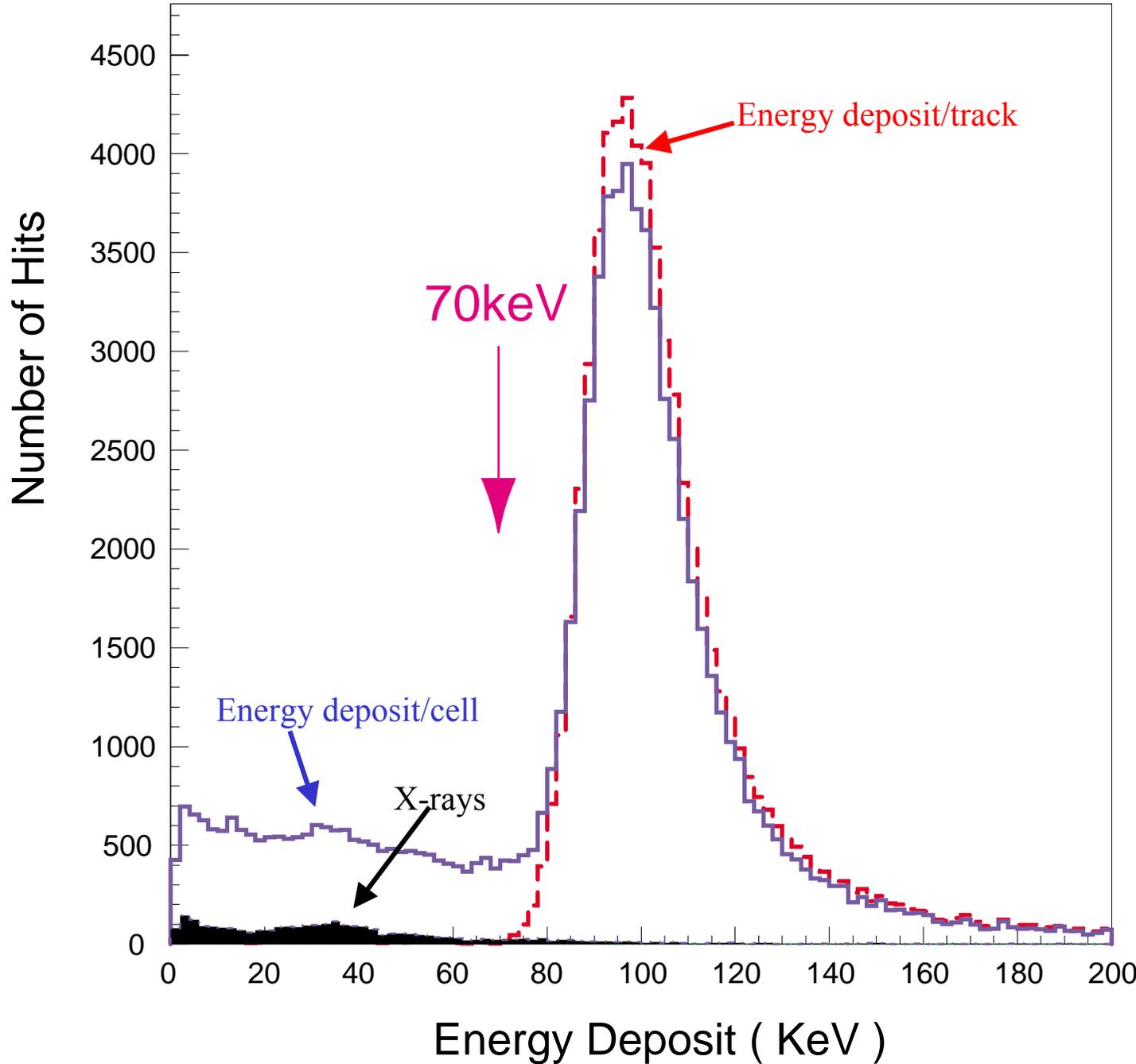
outer radius 8.5 cm

location (z) 176 and ~~177~~ cm from IP

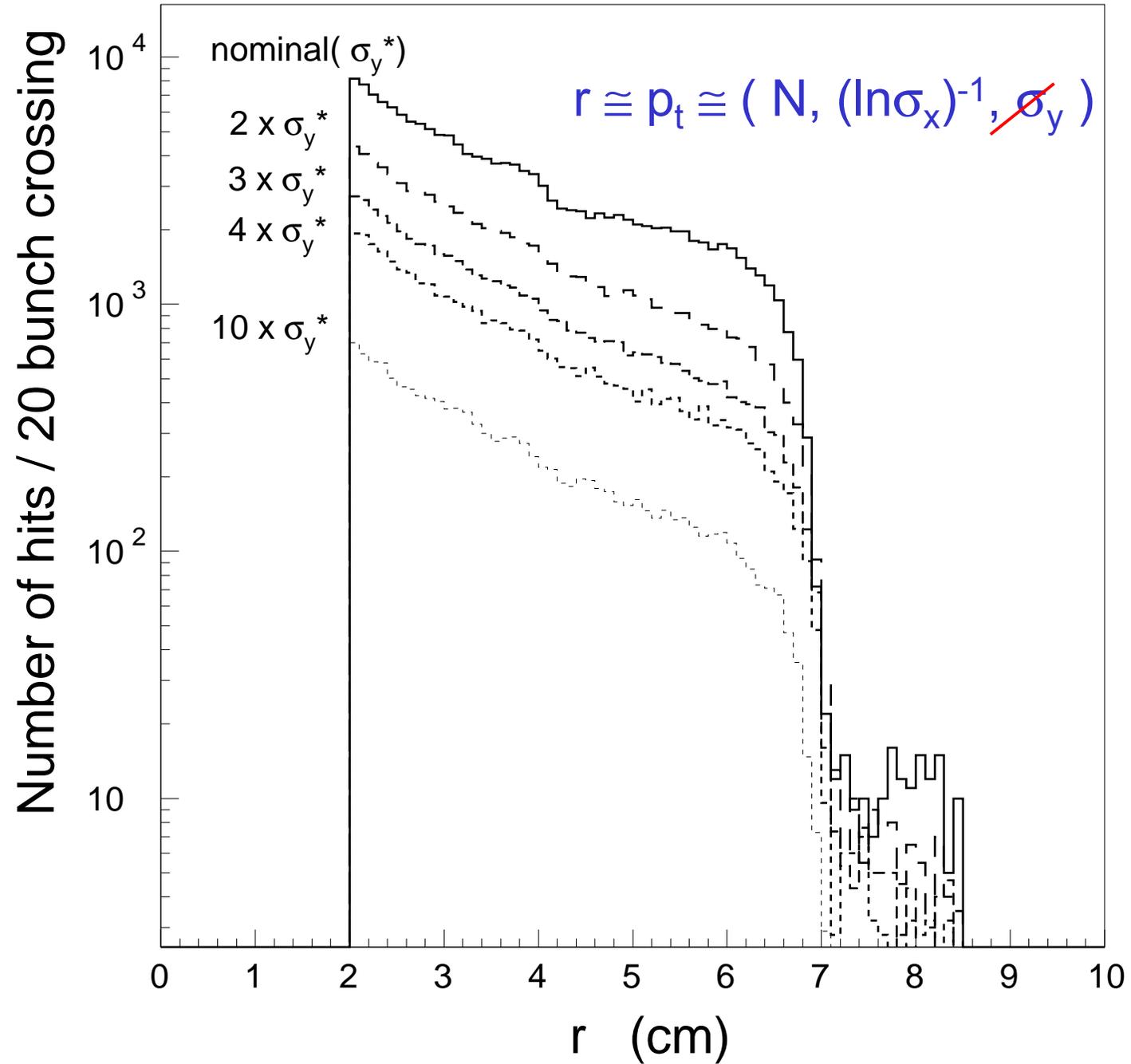
Measurement:

position and energy deposit

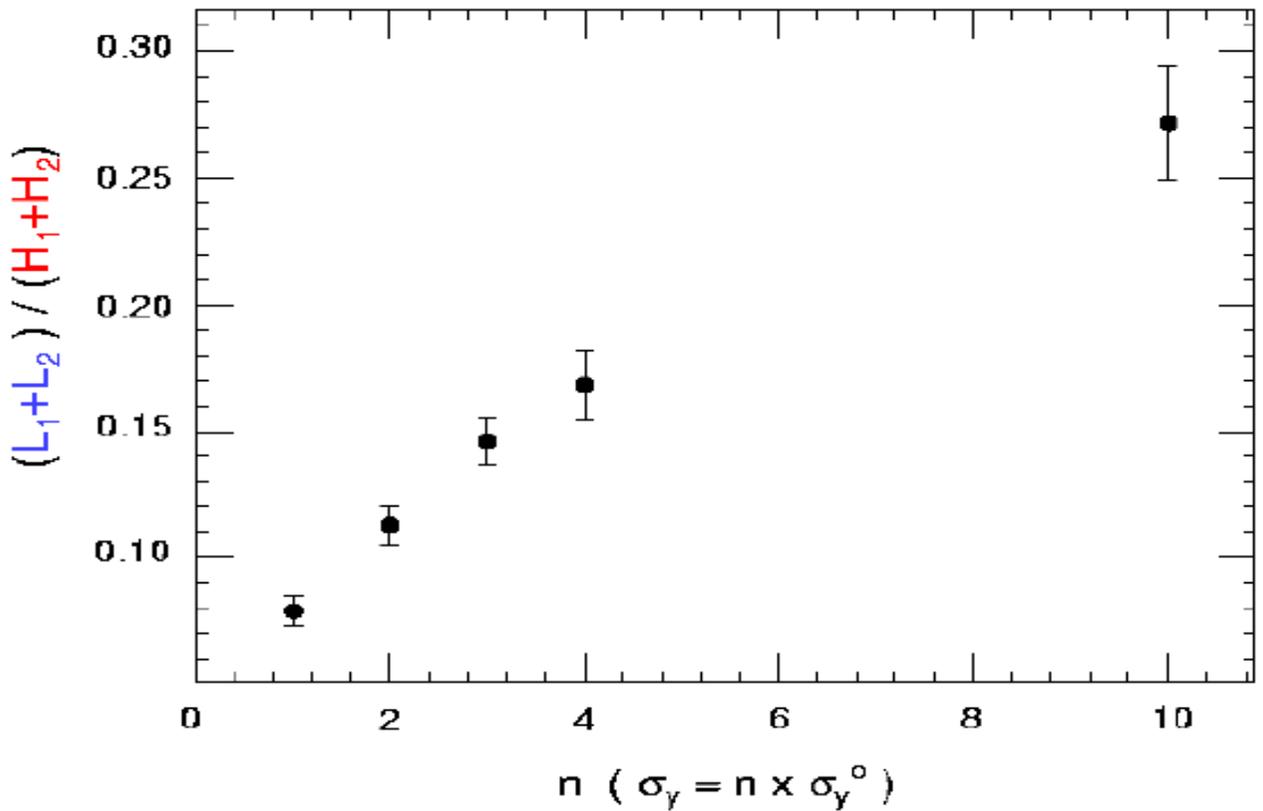
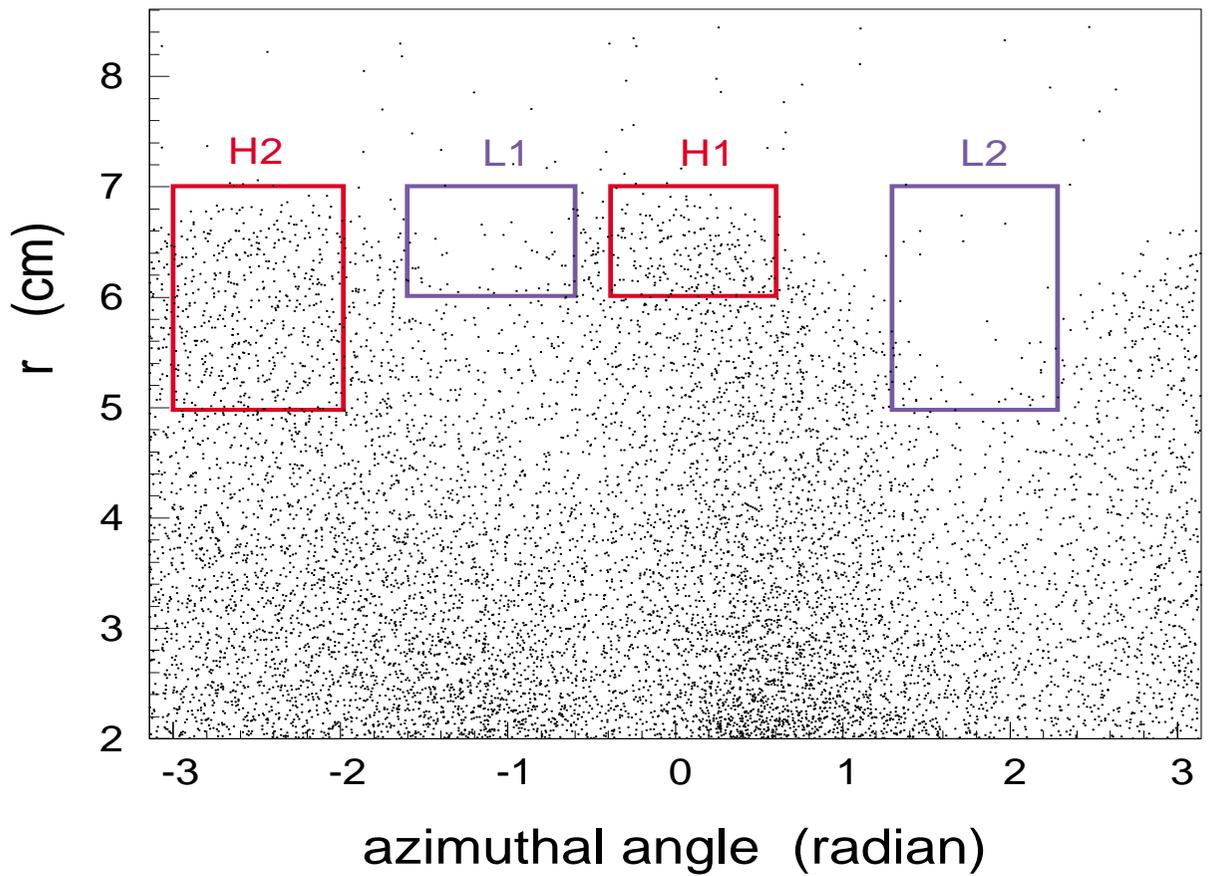
Pair Monitor



Pair Monitor



Pair Monitor



Requirements for the Pair Monitor

- Detect a few 100 MeV electrons.
 - 30 hits/mm²/train for $r = 5 \sim 7$ cm.
 - ~ 50 kRad/year.
 - ~ 70 keV threshold to reject X-rays.
 - Identification of bunch in a train.
 - Cover a circular area.
-
- Rate too high for a Si strip detector.
 - CCD does not have TDC for each pixel.
 - \rightarrow active pixel sensor.

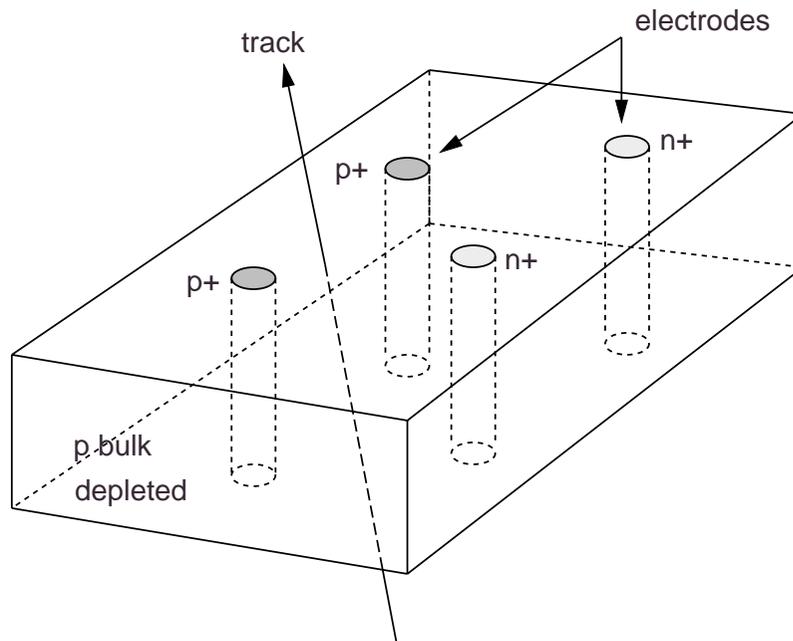
Use $100 \times 100 \mu\text{m}^2$ pixel.

TDC on each pixel.

Gating to reduce occupancy and/or

Multi hit TDC capability.

3D Pixel Sensor



Drift field parallel to the plane of sensor.

- Signal pulse is about $\times 10$ faster than typical pixel.
- $V_{\text{depletion}} \sim 5\text{V}$.
- Flexible geometry (e.g. trapezoid).
- Active all the way to the edge (no guard ring).

Detector Development

Good timing!

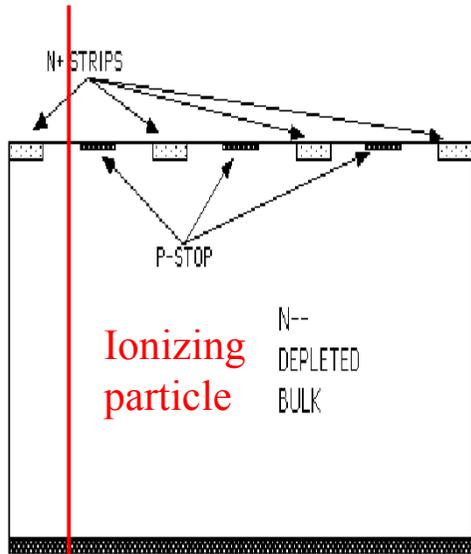


Figure (1A) ORTHOGONAL P+ STRIPS NOT TO SCALE

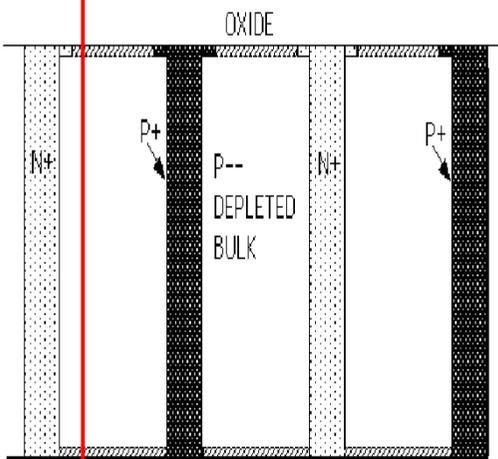
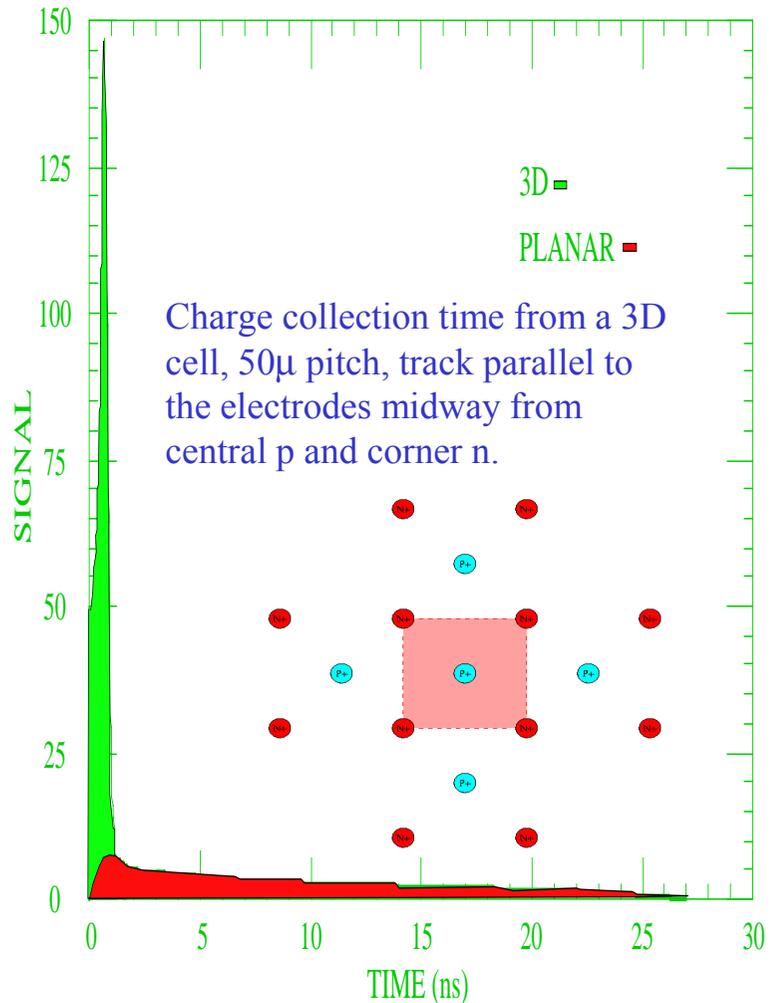


Figure (1B) NOT TO SCALE

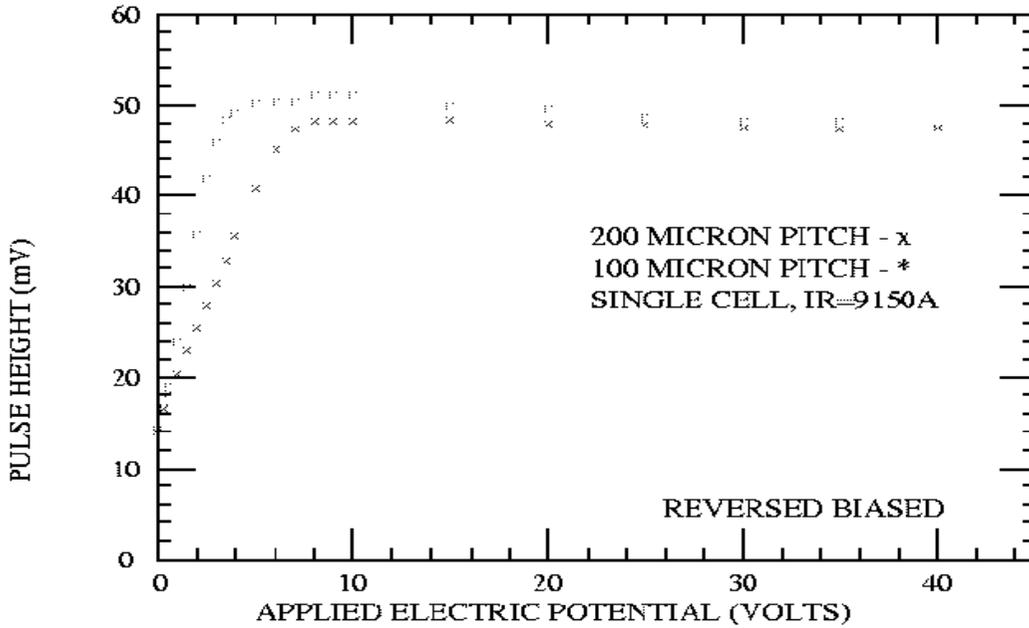


Reduction of distance between electrodes:

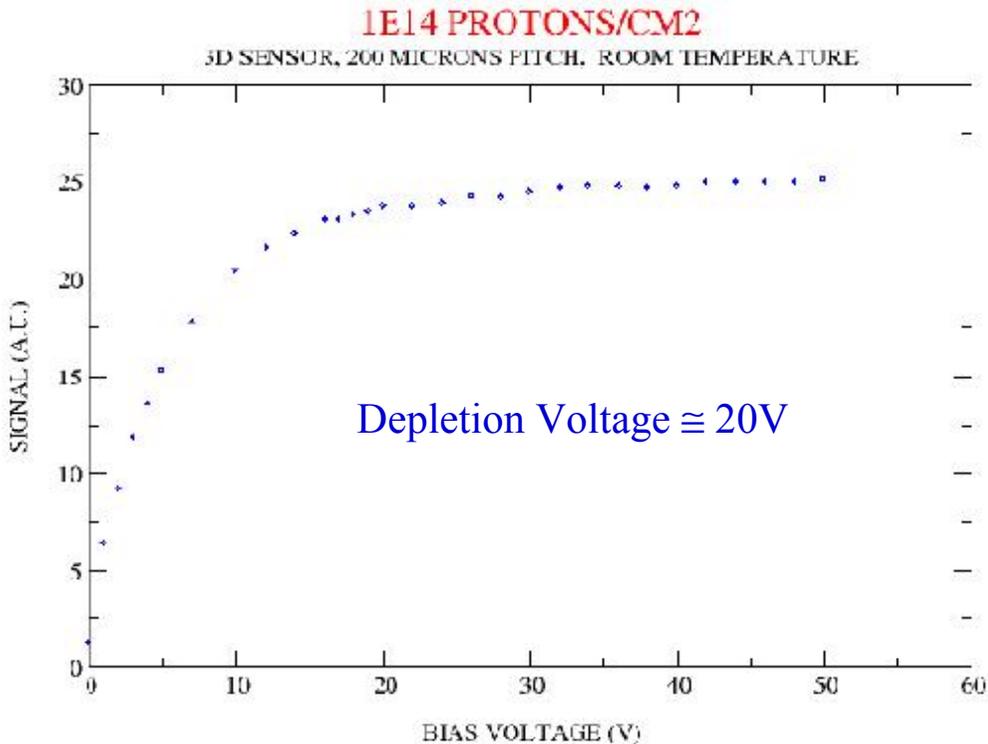
- Reduction of drift time
- Reduction of depletion voltage

Detector Development

IR tests show low depletion voltage



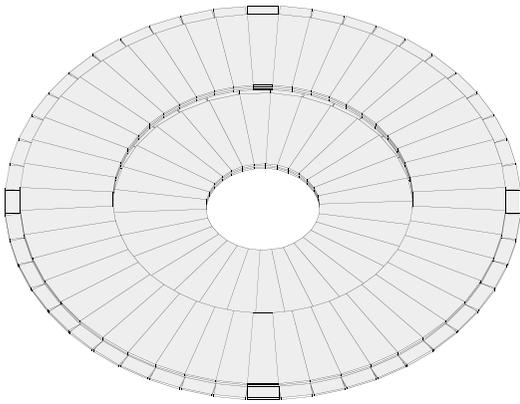
...also after 55 Mev proton irradiation



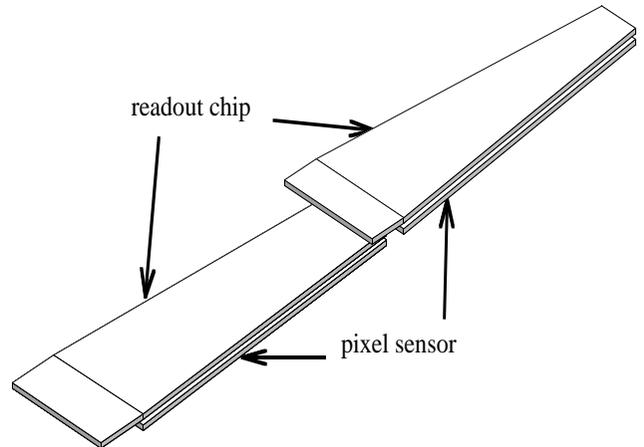
Pair Monitor Prototype

A set of 3D sensors currently in fabrication @SNF.

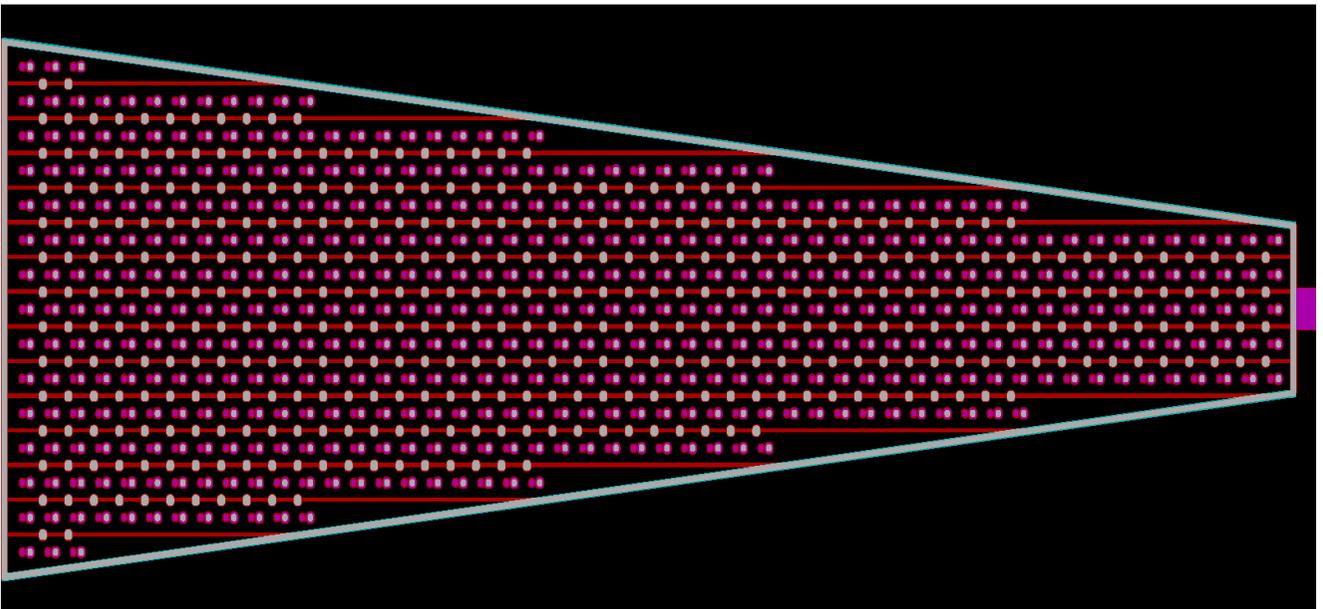
If all goes well, sensors available by the end of the year.



One disk showing the detector arrangement: top side facing the IP



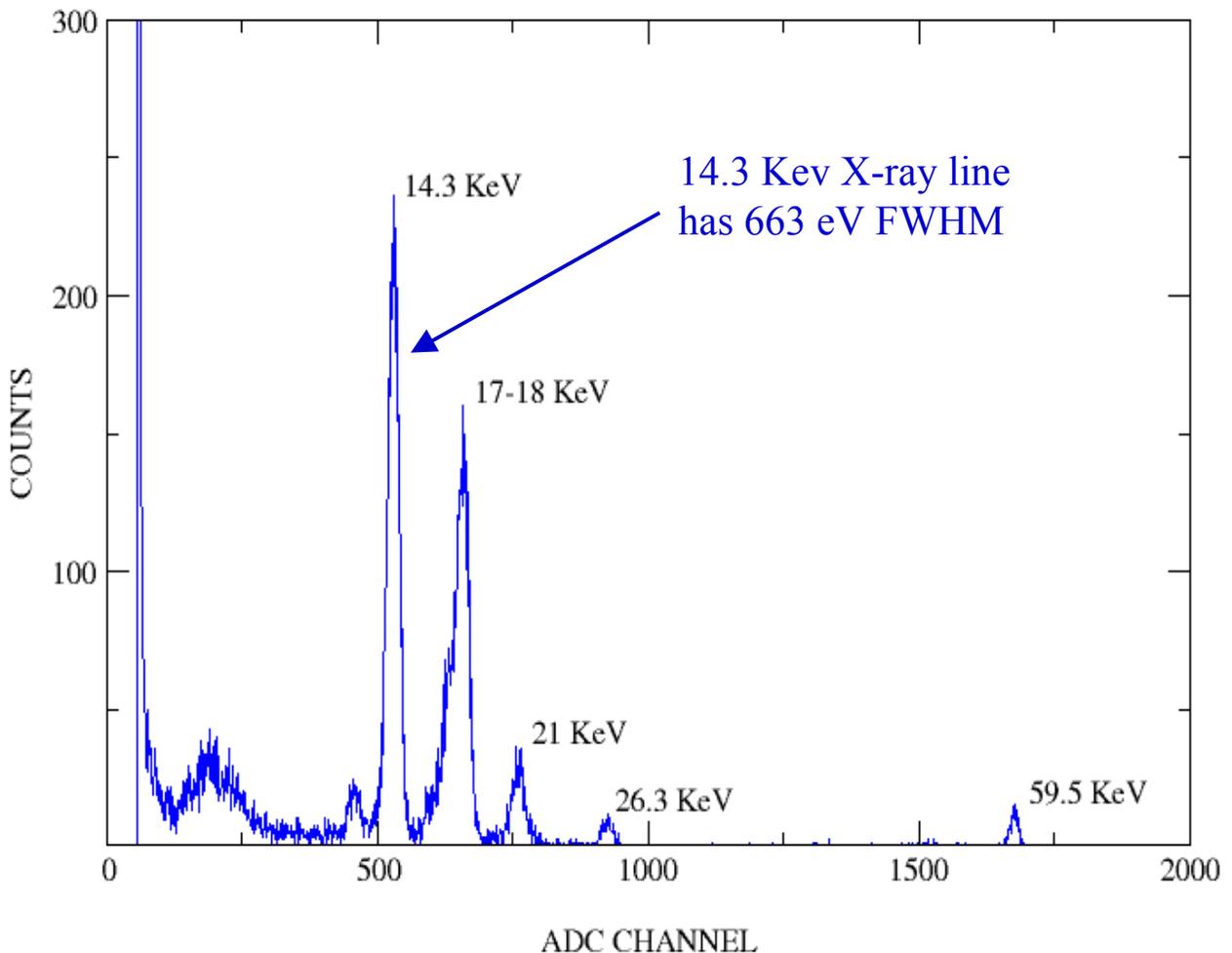
One trapezoidal component of the disk: sensor facing the IP



Detector Results - sensitivity

- Charge sensitive amp, 1 μ sec shaping time
- “Strip detector” with 14 P-type electrodes tied
- 200 micron pitch strip to strip, 100 micron between electrodes within a strip

AMERICIUM-241
3D - 200 MICRON PITCH

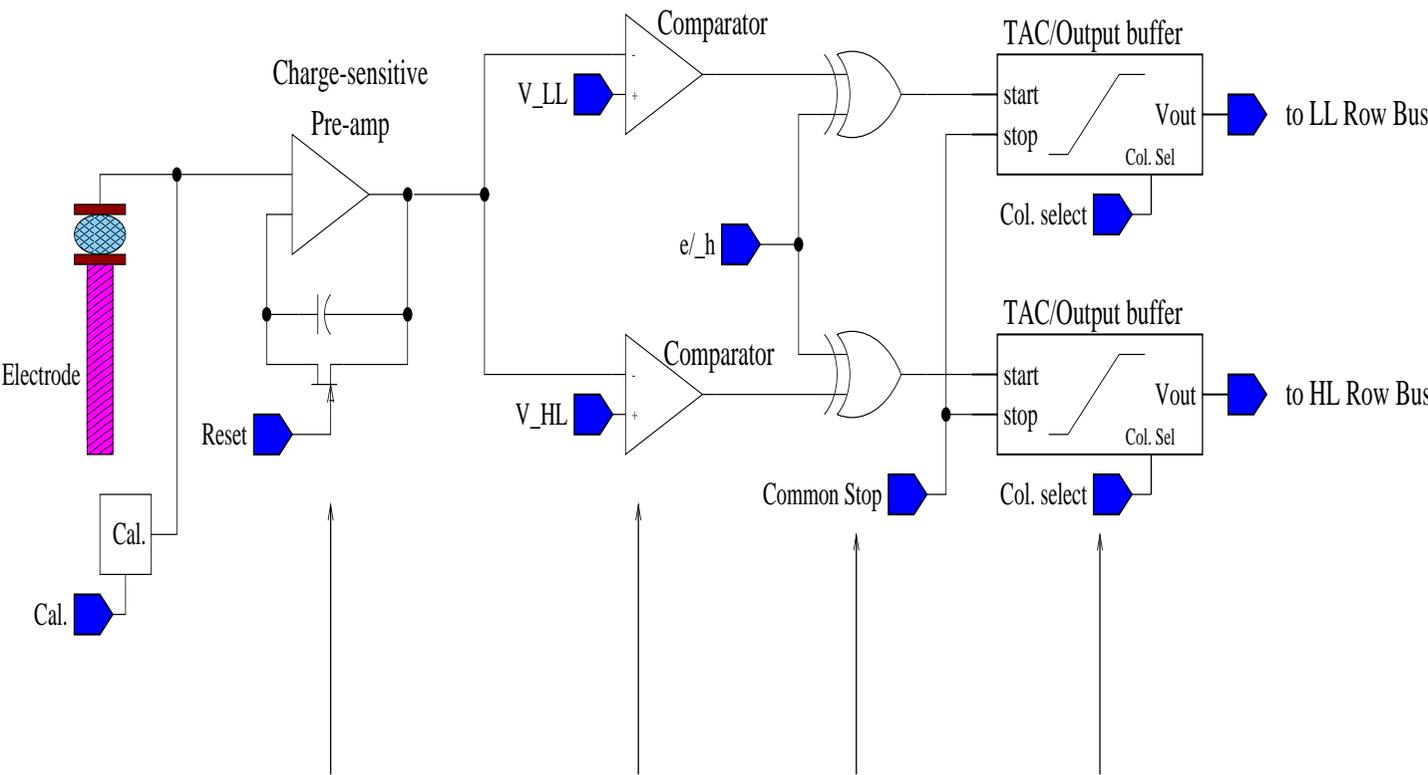


LCPIX0 Design Parameters

- **Sensor Thickness (100/300 μ m)**
 - Previous performance simulations based upon 300 μ m thick sensor, with 70keV threshold
 - Need simulation for thinner device (background rejection)
- **LCPIX0 Design:**
 - 100-300 μ m thickness (200-600 fF)
 - Good timing performance
 - Fit in 100 x 100 μ m footprint
 - Original spec. 5-15ns timing resolution
 - think can do better (see simulations)
 - Readout time target few ms (150 Hz trains)
 - 70keV Threshold

LCPIX0 Proposed Architecture

LCPIX0 Pixel Cell



Standard folded-cascode design

$\geq 1\text{mV/keV}$ gain
($\geq 23\text{mV/fC}$)

good timing performance

Standard topologies

$V_{LL} = 25\text{mV}$
 $V_{HL} = 50\text{mV}$

Evaluate overdrive

Can collect either holes or electrons

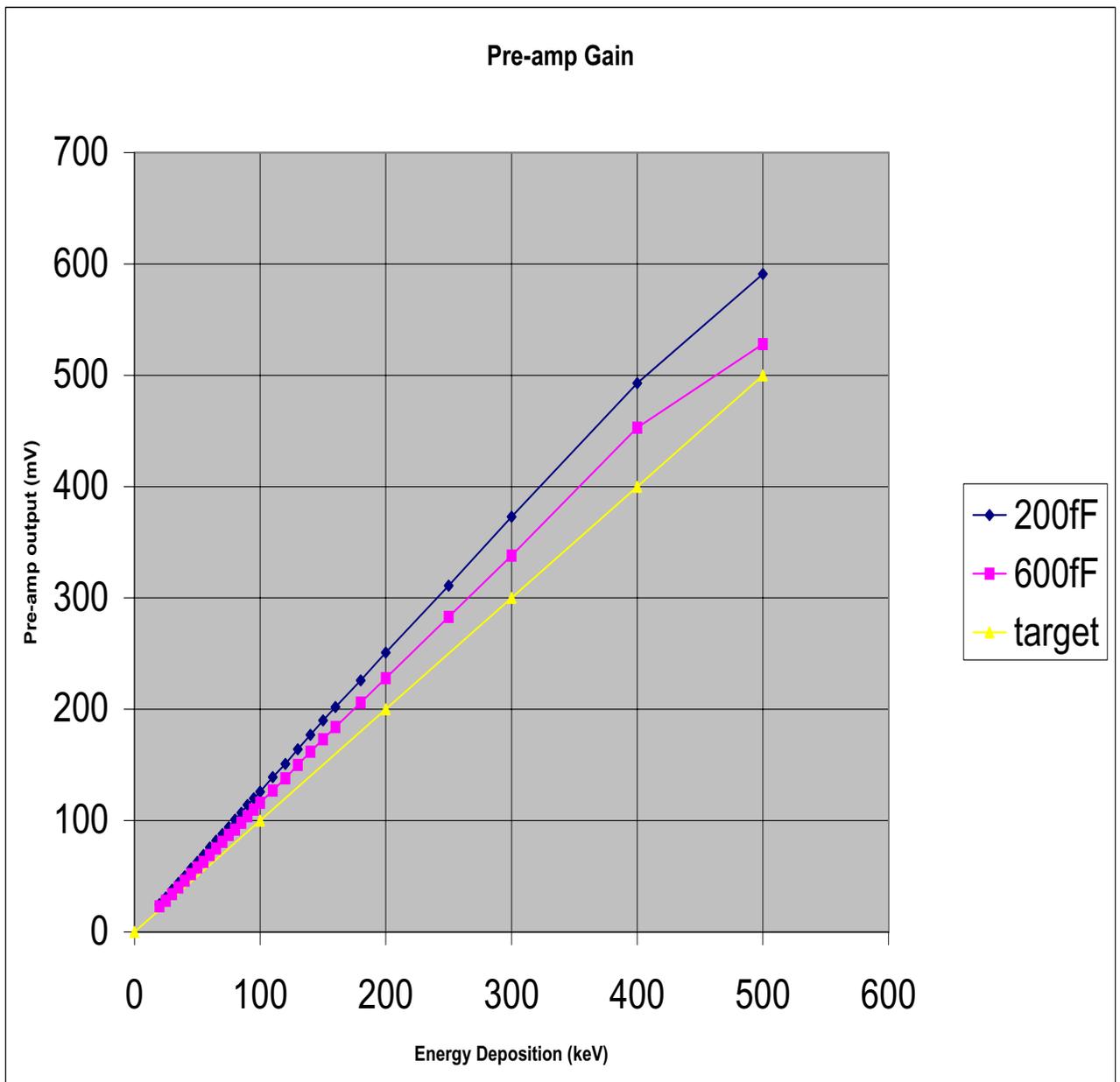
switched Isource into storage Cap

Common stop operation allows easy Zero Suppr.

LCPIX0

Pre-amp gain

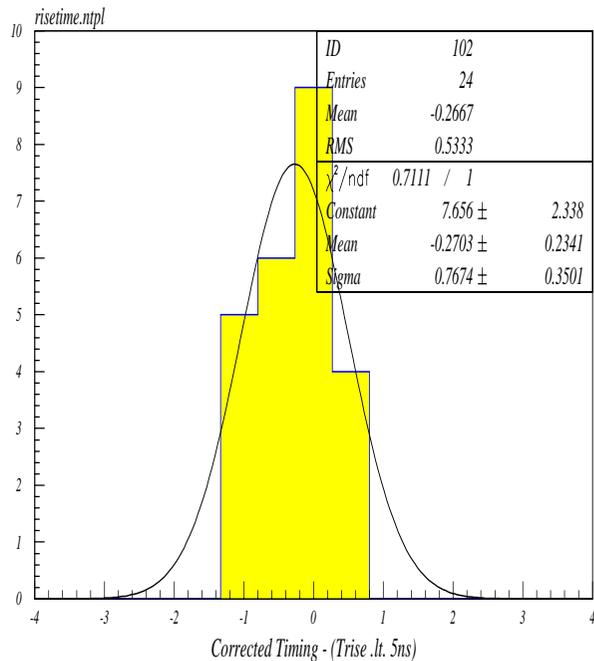
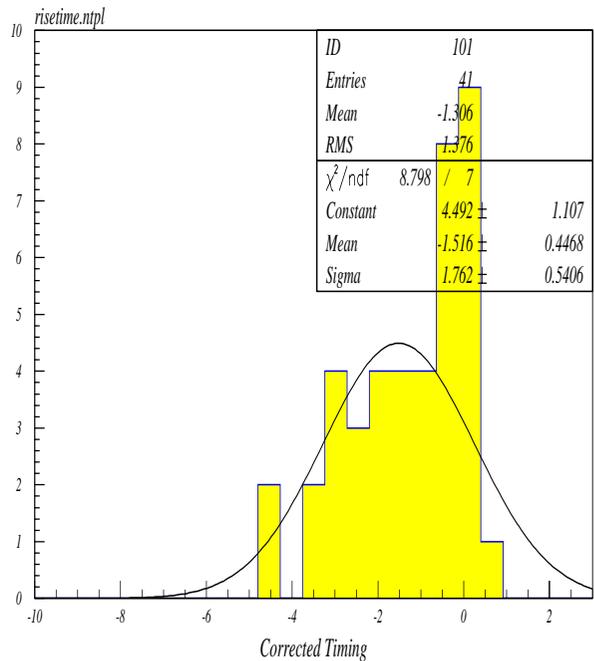
Possibility of using 100 μm or 300 μm thick sensor



LCPIX0 Timing

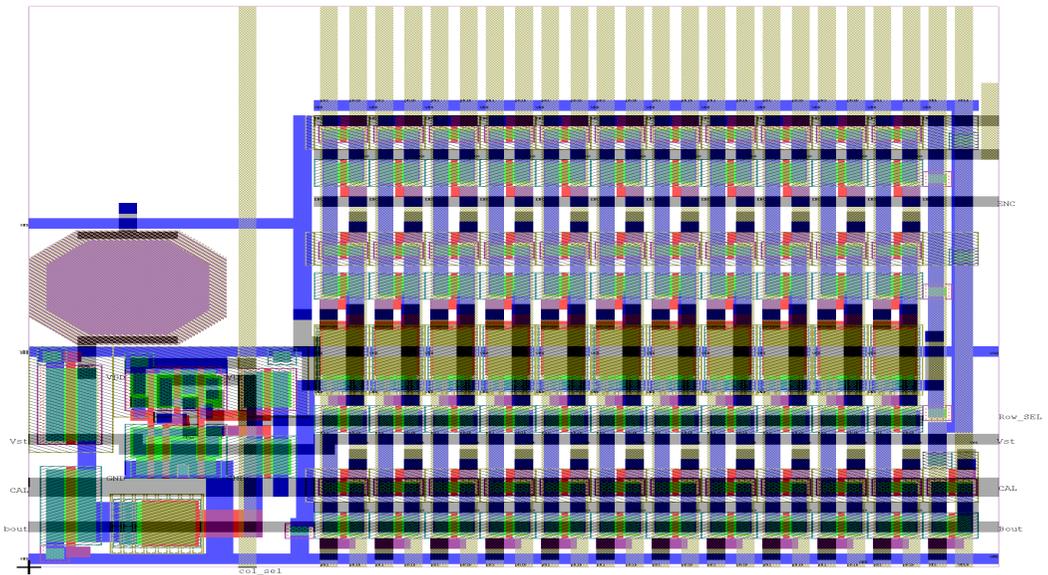
LCPIX0 Final Corrected Timing

With a time difference cut between T_{LT} and T_{HT} of less than 5 ns, a time resolution of better than 1 ns on the bunch timing can be reached

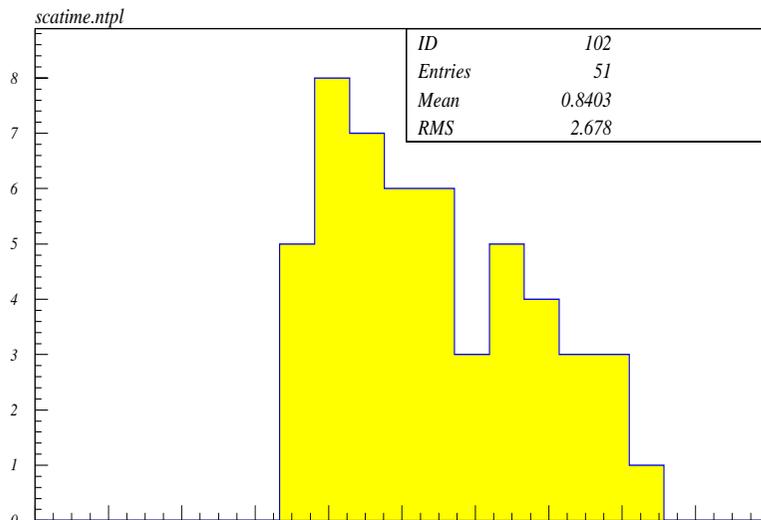


If occupancy is too high..

- External gating to set a window on a train
- Multi hit TDC on each pixel



LCSCA0 Timing Residuals (70keV, full train)



With a multi hit TDC the timing resolution is better than 3ns, to be compared with a bunch separation of about 3 (1.5) ns

LCPIX0 To Do List:

- Further simulation
 - Next logical step is to check performance for a realistic energy/risetime distribution
 - Results seem “good enough” for now:
 - no apparent problem with C_i
 - can set a clean, 70keV threshold
 - ns level resolution should be possible
- LCPIX0 Design
 - Rest of readout architecture
 - check settling time good enough to readout in a few ms for full-sized sensor
 - Layout: to fit in 100 x 100 μ m footprint
 - Possible submission by end 2000?

Conclusions

For the beam profile monitor we need a position dependent counting detector:

- Set a 70 Kev threshold on each ch.
- Have a small charge sharing



3D sensor seems appropriate and preliminary results look encouraging

The proposed electronics allows bunch identification in a train and a full read-out between trains.